



Cite this: *RSC Adv.*, 2025, 15, 5737

# Mechanism study of a novel modified mesoporous silicon-based NiT<sub>50</sub>/MCM-41 adsorbent for the selective adsorption of methylene blue from water†

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In this study, a new silica-based adsorbent strategy was developed to achieve a high adsorption capacity and high MB adsorption selectivity by impregnating a cationic [Ni(TEPA)]<sup>2+</sup> complex on a negatively charged silicon carrier, MCM-41. When the [Ni(TEPA)]<sup>2+</sup> loading was 50%, the MB adsorption capacity of the silicon-based adsorbent (NiT<sub>50</sub>/MCM-41) could reach 130 mg g<sup>-1</sup>, which was much higher than that of the original silicon-based MCM-41 adsorbent (23 mg g<sup>-1</sup>). Interestingly, NiT<sub>50</sub>/MCM-41 exhibited excellent MB adsorption selectivity in binary mixed dye solutions (MB/R6G, MB/RhB, and MB/MO). The adsorption kinetics and adsorption isotherm followed a second-order kinetic model and the Langmuir adsorption model, respectively. Experimental results showed that the aqueous solution of [Ni(TEPA)]<sup>2+</sup> can provide an alkaline environment to promote the deprotonation of Si–OH on the surface of silicon dioxide to form SiO<sup>-</sup>, which makes the surface negatively charged, and [Ni(TEPA)]<sup>2+</sup> effectively occupies these negatively charged sites through Coulomb interactions to better accommodate the cationic complex [Ni(TEPA)]<sup>2+</sup>. Structural characterization and analysis confirmed that the NiO<sub>x</sub> and NiC<sub>x</sub> components were successfully introduced in the mesoporous channels of the silicon-based adsorbent through heat treatment, enabling the cationic dye to be immobilized on the silicon-based adsorbent through Lewis acid–base interaction, which effectively improved the adsorption capacity and adsorption selectivity towards MB.

Received 22nd November 2024  
Accepted 30th January 2025

DOI: 10.1039/d4ra08300h

rsc.li/rsc-advances

## 1 Introduction

With the rapid industrialization, urbanization and population growth, water pollution has become increasingly severe worldwide.<sup>1</sup> Dyes, produced in large quantities and widely applied in textiles, paper, printing, food, cosmetics, hair dyes, wood staining, pharmaceuticals, and leather manufacturing as well as in agricultural, biological, and chemical research,<sup>2,3</sup> are a significant contributor to water contamination. Dyes are carcinogenic, teratogenic, and mutagenic. Thus, their presence can not only cause severe damage to the natural environment, disrupting ecosystems and contaminating resources, but also have grave impacts on industrial activities and the daily life of people, posing significant risks to human health and overall well-being.<sup>4–7</sup> Methylene blue (MB) is considered one of the

most common aromatic cationic dyes, and related studies have proven that exposure to MB can cause skin damage and eye burns, while its direct ingestion can cause an increased heart rate, causing indigestion and methemoglobinemia.<sup>8</sup> Therefore, preventing the destructive effects of harmful dye wastewater on water, soil, animals, plants, and humans through the effective treatment of harmful dye wastewater is highly important.

To eliminate the contamination of dyes, various technologies have been developed and applied, such as physical,<sup>9</sup> chemical,<sup>10–12</sup> biological treatment,<sup>13</sup> and photodegradation<sup>14–16</sup> methods. Among the widely adopted solutions, adsorption stands out for its simple operation, low energy consumption, and ease of large-scale application, showing great potential for wastewater treatment. The efficiency of the adsorption process primarily relies on the selection of appropriate adsorbents.<sup>17</sup> Numerous adsorbents have been studied for dye removal from wastewater. Recently, the development of selective adsorbents for the adsorption of specific dyes has attracted considerable interest. These adsorbents enable the selective separation of dye mixtures in industrial wastewater treatment. Numerous adsorbents with selective adsorption capabilities have been reported to date, such as metal–organic frameworks, nitrogen-doped nanoporous carbon, and LnCu–polyoxometalates.<sup>18–20</sup> However, given the complexity of real industrial wastewater

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† Electronic supplementary information (ESI) available. See DOI: <https://doi.org/10.1039/d4ra08300h>

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treatment environments, creating novel sorbent materials with high capacity, high selectivity, and high energy efficiency for the adsorption of dyes from water remains a significant challenge.

Compared with traditional solid adsorbents, mesoporous molecular sieve MCM-41 is increasingly used as an adsorbent in environmental remediation due to its highly ordered pore structure, large pore volume and adjustable size, and high specific surface area.<sup>21</sup> However, pure MCM-41 lacks active adsorption sites.<sup>22,23</sup> The surface of the pores in MCM-41 has easy-to-modify silica hydroxyl groups, and thus functionalized groups can be firmly bonded to its pore surface by a silylation reaction. Therefore, it is essential to develop functionalized silicon-based materials through surface modification with silica to serve as adsorbents for the selective adsorption of dyes in wastewater.

Given the complexity of the actual industrial wastewater environment, this study aimed to develop a novel and highly efficient adsorbent for the selective removal of methylene blue (MB) from various ionic wastewater. By exploring a unique "[Ni(tepa)]<sup>2+</sup> modification-thermal treatment" strategy, the limitations of traditional adsorbents and pure MCM-41 could be overcome. Tetraethylenepentamine (tepa) is used to form a coordination cation [Ni(tepa)]<sup>2+</sup> with nickel. This complex not only provided an alkaline environment to promote the interaction with the silica surface but also occupied the negative charge sites through Coulomb interactions. Additionally, through thermal treatment, NiO<sub>x</sub> and NiC<sub>x</sub> components were successfully introduced onto the surface of the silicon-based adsorbent, enhancing its selective adsorption capacity for MB. Thus, this study provides a new perspective and method for the development of high-performance adsorbents in the field of wastewater treatment, addressing the urgent need for effective solutions to deal with dye-contaminated wastewater.

## 2 Materials and methods

### 2.1 Material synthesis

**2.1.1 Preparation of silicon support MCM-41.** The silicon support MCM-41 was prepared using hexadecyl trimethyl ammonium bromide (CTAB, AR) and tetraethyl orthosilicate (TEOS, AR) under alkaline conditions following the Stöber method reported previously.<sup>24</sup> Briefly, CTAB (0.73 g), ethanol (114.8 g) and H<sub>2</sub>O (238.8 g) were mixed at 35 °C to obtain a clear solution. Then, NH<sub>3</sub> (4.35 g) was added, and the mixture was stirred for 30 min. Subsequently, TEOS (4.5 g) was rapidly added to the solution, and the mixture was stirred for 24 h. The obtained suspension was centrifuged to obtain a white solid, which was subsequently washed with ethanol three times and washed with deionized water once. Finally, the obtained white solid was dried overnight and transferred to a muffle furnace, and calcination removed the templating agent (the roasting conditions were heating at a rate of 2 °C min<sup>-1</sup> to 550 °C for 6 h to remove the templating agent).

**2.1.2 Preparation of silicon-based adsorbents.** The nickel precursor solution was created by dissolving 5 mmol of Ni(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O (Sinopharm, AR) in 12 mL of distilled water. Then, 10 mmol of TEPA (Sinopharm, CP) was added dropwise to

the nickel solution, and the mixture was stirred slowly at 30 °C for 1 h to form an [Ni(tepa)]<sup>2+</sup> complex solution. Then, 0.1 g of silica support was added to the prepared [Ni(tepa)]<sup>2+</sup> solution and mixed using ultrasonication for 1 h. Subsequently, this mixture was dried at 80 °C for 12 h, and then ground into a fine powder. Powders with different [Ni(tepa)]<sup>2+</sup> loadings (10–70 wt%) were produced. Following our previous work,<sup>25</sup> the powder was placed in a 50 mL covered crucible and heated in static air to 400 °C. The temperature was increased at a rate of 4 °C min<sup>-1</sup> and maintained for 2 h. The final adsorbents were labeled NiT<sub>X</sub>/MCM-41, where X represents the loading amount of [Ni(tepa)]<sup>2+</sup> in the silica support.

### 2.2 Details of the experiment

**2.2.1 Dye adsorption experiment.** Firstly, 12 mg of NiT<sub>X</sub>/MCM-41 was mixed with 30 mL of an aqueous solution of organic dye (MB, R6G, RhB, or MO) at a certain concentration. The beaker was shaken at 30 °C at a constant shaking speed of 300 rpm for a specified duration. After the adsorption process, the supernatant was collected from the stock solution using a syringe filter (hydrophobic, 0.22 μm). The residual dye concentration was measured using UV-vis spectroscopy after dilution (if necessary) at the maximum wavelengths. The above-mentioned steps were repeated multiple times.

The adsorption capacities  $Q_t$  and  $Q_e$  were calculated using eqn (1) and (2), as follows:

$$Q_t = V(C_0 - C_t)/m \quad (1)$$

$$Q_e = V(C_0 - C_e)/m \quad (2)$$

where  $C_0$ ,  $C_t$ , and  $C_e$  represent the initial concentration, the concentration at a given time ( $t$ ), and the equilibrium concentration of the dye (mg L<sup>-1</sup>), respectively;  $m$  is the mass of NiT<sub>X</sub>/MCM-41 (g); and  $V$  is the volume of the solution (L).

**2.2.2 Effect of pH on dye adsorption.** The pH of the MB solution was adjusted to 2–10 with 0.1 M NaOH or HCl aqueous solution. Then, 12 mg adsorbent was mixed with 25 mL of a 25 mg per L MB solution with a pH in the range of 2–10. Next, 5 mL of phosphate-buffered saline (PBS) was added to ensure that there was no significant change in the pH value. As before, the beakers were shaken (300 rpm) for 30 min at 30 °C. The above-mentioned steps were repeated multiple times.

**2.2.3 Effect of the contact time and initial concentration.** The adsorption experiments were performed by mixing 12 mg of adsorbent with 25 mL of MB solutions of different concentrations (30, 40, 50, or 100 mg L<sup>-1</sup>), and then 5 mL of phosphate-buffered saline (PBS) added to ensure that the differences in adsorption were caused by the concentration. Shaking was performed for different contact times (2, 5, 10, 15, 20, 30, 45, or 60 min). The above-mentioned steps were repeated multiple times.

**2.2.4 Kinetic studies and adsorption isotherm.** Two kinetic models (pseudo-first-order<sup>26</sup> and pseudo-second-order<sup>27</sup>) and two isotherm models (Langmuir<sup>28</sup> and Freundlich<sup>29</sup>) were investigated.



The two kinetic models can be described in linear form as follows:

$$\ln(Q_e - Q_t) = \ln(Q_e) - k_1 t \quad (3)$$

$$t/Q_t = 1/k_2 Q_e^2 + t/Q_e \quad (4)$$

where  $Q_e$  and  $Q_t$  ( $\text{mg g}^{-1}$ ) represent the amount of **MB** adsorbed at equilibrium and a specific time (min), respectively.  $k_1$  ( $\text{min}^{-1}$ ) is the rate constant of the pseudo-first-order model and  $k_2$  ( $\text{g mg}^{-1} \text{min}^{-1}$ ) is the pseudo-second-order rate constant.

Also, the Langmuir and Freundlich model can be described in linear form as follows:

$$C_e/Q_e = 1/Q_0 K_L + 1/Q_0 C_e \quad (5)$$

$$\ln Q_e = \ln K_F + 1/n \ln C_e \quad (6)$$

where  $K_L$  ( $\text{L mg}^{-1}$ ) and  $Q_0$  ( $\text{mg g}^{-1}$ ) are the Langmuir constants involved in adsorption rate and adsorption capacity.  $K_F$  and  $n$  are Freundlich constants.

**2.2.5 Selective separation of mixed solutions of MB/R6G, MB/RhB, and MB/MO.** A solution of **MB** was combined (1 : 1, v/v) with a solution of identical concentration ( $25 \text{ mg L}^{-1}$ ) of **R6G**, **RhB**, or **MO** to produce mixtures of **MB/R6G**, **MB/RhB**, and **MB/MO**. In these experiments, 12 mg of adsorbent was added to 30 mL of the mixed **MB/R6G**, **MB/RhB**, or **MB/MO** solution. The adsorption process was observed using UV-vis spectroscopy.

## 2.3 Characterization

UV-vis spectroscopic studies were performed on a UV1800 spectrophotometer. The crystal phase of the catalyst powder was characterized using a Rigaku Smart Lab (Japan) X-ray diffractometer (XRD) with  $\text{Cu K}\alpha$  (40 kV, 100 A) radiation at a test wavelength of 0.1542 nm, scanning rate of  $10^\circ \text{ min}^{-1}$ , and scanning  $2\theta$  range of  $5\text{--}80^\circ$ . The surface morphologies and sizes of the samples were examined by scanning electron microscopy (SEM) on a HITACHI SU8010 instrument with an accelerating voltage of 5.0 kV, and all the samples were sputtered with a thin gold film. X-ray photoelectron spectroscopy (XPS) was tested using a Thermo Scientific K-Alpha instrument in the United States to determine the surface composition of the catalyst and the valence state of the elements. The results were corrected for the charge effect based on the position of the C (1s) reference peak at 284.8 eV.  $\text{N}_2$  isotherms were measured using a Quantachrome autosorb-iQ2 gas adsorption analyzer at  $-196^\circ \text{C}$ . The zeta potential values of RSA and the composites were measured using a Zetasizer Nano S90. Fourier transform infrared (FTIR) spectroscopy (Nicolet Nexus 410) was used to record the infrared spectra (IR) in the range of 4000 to  $400 \text{ cm}^{-1}$ .

## 3 Results and discussion

### 3.1 Characterization

**3.1.1 SEM images analysis.** The morphological characteristics of MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$  were observed by scanning electron microscopy (SEM) and transmission electron

microscopy (TEM), as shown in Fig. 1a–c. The SEM and TEM images both show the morphological structures as spherical particles with a uniform size (close to 500 nm), featuring a certain degree of stacking and aggregation. There was no significant change in the morphology of the sample before and after modification. This indicates that the morphology of the mesoporous silicon support was preserved after loading  $[\text{Ni}(\text{tepa})]^{2+}$  and undergoing appropriate thermal treatment modification.

**3.1.2 XRD spectral analysis.** Small-angle X-ray diffraction (SAXRD) can be used to characterize the structure of ordered porous samples. The SAXRD patterns of the mesoporous silicon support MCM-41 and as-prepared  $\text{NiT}_{50}/\text{MCM-41}$  are shown in Fig. 1d. In this study, the mesoporous silica MCM-41 prepared exhibited weak peaks at the  $2\theta$  values of  $2.52^\circ$  and  $3.5\text{--}5^\circ$ , corresponding to the (100) and (110), and (200) crystal planes of the hexagonal structure, respectively (no. 01-073-0626).<sup>30,31</sup> The diffraction peak for the prepared  $\text{NiT}_{50}/\text{MCM-41}$  remained unchanged, signifying that the ordered hexagonal mesoporous pore structure was maintained after loading  $[\text{Ni}(\text{tepa})]^{2+}$  on the mesoporous silicon support MCM-41 and subsequent heat treatment.<sup>32</sup> Moreover, a decrease in peak intensity was observed, indicating the partial loss of the periodicity of the MCM-41 pore structure, which is likely due to the  $[\text{Ni}(\text{tepa})]^{2+}$  loading within the pores of the mesoporous silica MCM-41. The inset figure in Fig. 1d shows the wide-angle XRD (WAXRD) patterns of  $\text{NiT}_{50}/\text{MCM-41}$ , which feature a broad diffusion peak at  $20\text{--}30^\circ$ , suggesting that the primary component of  $\text{NiT}_{50}/\text{MCM-41}$  is the amorphous silica phase.<sup>33</sup> The absence of characteristic peaks for nickel oxide or other Ni species in  $\text{NiT}_{50}/\text{MCM-41}$  implies that the Ni species may exist as finely dispersed nanoparticles and/or as amorphous particles within the framework of  $\text{NiT}_{50}/\text{MCM-41}$ .<sup>34</sup>

**3.1.3  $\text{N}_2$  physical adsorption analysis.** The textural features (surface area, pore volume, and pore size) were characterized *via* physical nitrogen adsorption. Fig. 1e and f show the nitrogen adsorption isotherms and pore size distribution curves for the MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$  samples, respectively. Fig. 1e reveals a type IV isotherm with a capillary condensation step, which is the typical pattern for mesoporous materials according to the IUPAC classification, indicating the presence of mesoporous structures in both MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$ .<sup>31</sup> These results indicate that the silicon-based adsorbent prepared by the “[ $\text{Ni}(\text{tepa})$ ] $^{2+}$  modification-thermal treatment” method retained the ordered hexagonal mesoporous structure of the mesoporous silica support (MCM-41), which is consistent with the XRD results. Fig. 1f indicates that both MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$  have narrow mesopores with a size in the range of 2–3 nm. However, the pore size distribution of  $\text{NiT}_{50}/\text{MCM-41}$  shifted slightly towards a smaller size. The surface area, pore volume, and average pore size of MCM-41 are  $1558 \text{ m}^2 \text{ g}^{-1}$ ,  $0.79 \text{ cm}^3 \text{ g}^{-1}$ , and 2.37 nm, respectively. After modification, these values for  $\text{NiT}_{50}/\text{MCM-41}$  decreased to  $958 \text{ m}^2 \text{ g}^{-1}$ ,  $0.52 \text{ cm}^3 \text{ g}^{-1}$ , and 2.15 nm, respectively, due to the incorporation of Ni species within the channels of the MCM-41 support. These results indicate that Ni species were successfully introduced into MCM-41.



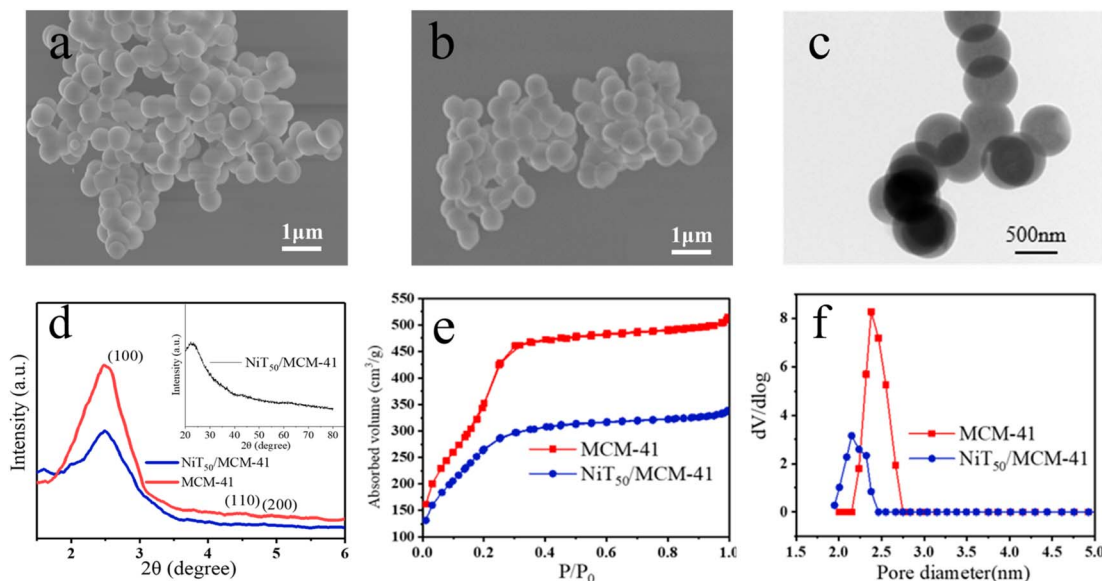


Fig. 1 SEM images of (a) MCM-41 and (b) NiT<sub>50</sub>/MCM-41; (c) HRTEM images of NiT<sub>50</sub>/MCM-41; (d) XRD results for MCM-41 and NiT<sub>50</sub>/MCM-41; (e) N<sub>2</sub> adsorption isotherms of MCM-41 and NiT<sub>50</sub>/MCM-41 and (f) pore size distribution analysis for MCM-41 and NiT<sub>50</sub>/MCM-41.

### 3.2 Unary adsorption performance for MB

The adsorption properties of the as-prepared silicon-based materials with different loading masses of [Ni(tepa)]<sup>2+</sup> (10–70 wt%) for **MB**, followed by thermal treatment at a temperature of 400 °C were investigated (Fig. 2a). The adsorption of **MB** by NiT<sub>x</sub>/MCM-41 was, in all cases, much better than the adsorption by the MCM-41 support (0% in Fig. 2a). As the [Ni(tepa)]<sup>2+</sup> loading mass gradually increased, the **MB** adsorption capacity of NiT<sub>x</sub>/MCM-41 first increased rapidly, but then decreased gradually. In the loading range of 0–20%, the adsorption capacity of the as-prepared adsorbents increased rapidly with an increase in loading mass. The **MB** adsorption capacity of NiT<sub>20</sub>/MCM-41 was 102 mg g<sup>−1</sup>, which was much greater than that of the MCM-41 support (23 mg g<sup>−1</sup>). When the [Ni(tepa)]<sup>2+</sup> loading was 50%, the adsorption of **MB** by NiT<sub>50</sub>/MCM-41 was 130 mg g<sup>−1</sup>, which is the maximum adsorption performance. Also, it exhibited a better adsorption performance compared to other silica-based adsorbents (Table 1). With a further increase in the loading amount of [Ni(tepa)]<sup>2+</sup>, an excessive amount of [Ni(tepa)]<sup>2+</sup> will aggregate within the pore channels, resulting in an uneven distribution of active sites, increase in steric hindrance, and reduction in the effective contact of adsorbate molecules, thus decreasing the adsorption capacity. The NiT<sub>50</sub>/MCM-41 catalyst was tested for multiple cycles under the same conditions, and the results are shown in Fig. S1,† which shows that its adsorption capacity did not significantly decrease.

Fig. 2b illustrates the influence of the pH of the **MB** aqueous solution on the adsorption of **MB** by MCM-41 and NiT<sub>50</sub>/MCM-41, with pH values in the range of 2 to 10. The **MB** adsorption capacities of both MCM-41 and NiT<sub>50</sub>/MCM-41 increased with an increase in pH. However, notable differences between MCM-41 and NiT<sub>50</sub>/MCM-41 were also evident. When the pH value was between 7 and 10, the adsorption capacity of MCM-41

rapidly increased to 100 mg g<sup>−1</sup> from 20 mg g<sup>−1</sup>. This may be because with an increase in the concentration of OH<sup>−</sup> ions, the negative charge on the surface of MCM-41 increased, which is more favorable for the adsorption of **MB** via electrostatic interactions. However, in the case of NiT<sub>50</sub>/MCM-41, the adsorption capacity for **MB** increased significantly between pH 3 and 7 but changed minimally between pH 7 and 10. These findings indicate that the synthesized silicon-based adsorbent, NiT<sub>50</sub>/MCM-41, possesses strong adsorption capacity under both acidic and basic conditions. Additionally, the considerable differences between MCM-41 and NiT<sub>50</sub>/MCM-41 suggest that electrostatic interactions alone may not account for the adsorption behavior of NiT<sub>50</sub>/MCM-41 toward **MB**.

The effects of varying contact times and initial concentrations of **MB** aqueous solution on the adsorption of **MB** by NiT<sub>50</sub>/MCM-41 were examined, and the results are presented in Fig. 2c and d, respectively. According to Fig. 2c, the adsorption capacity was 50 mg g<sup>−1</sup> within the first 30 s, and after 20 min, it began to stabilize at about 130 mg g<sup>−1</sup>, showing only slight changes with further contact time. Fig. 2d demonstrates that the adsorption capacity increased with higher initial **MB** concentrations. When the initial concentration of the **MB** aqueous solution reached 80 mg L<sup>−1</sup>, the adsorption capacity of NiT<sub>50</sub>/MCM-41 was 200 mg g<sup>−1</sup>. The minimum adsorption capacity is also an important index for evaluating the adsorption performance of an adsorbent. The **MB** dye has a characteristic absorption peak in the UV-vis spectrum, which can reflect the concentration of dye in aqueous solutions. Fig. S6† displays the UV-vis spectra of **MB** aqueous solutions with varying initial concentrations (15 mg L<sup>−1</sup>, 10 mg L<sup>−1</sup>, and 5 mg L<sup>−1</sup>) before and after adsorption by NiT<sub>50</sub>/MCM-41. For all three tested concentrations, the characteristic peaks of **MB** in the samples nearly vanished post-adsorption. The inset photograph demonstrates that the solution turned colorless after the adsorption process.





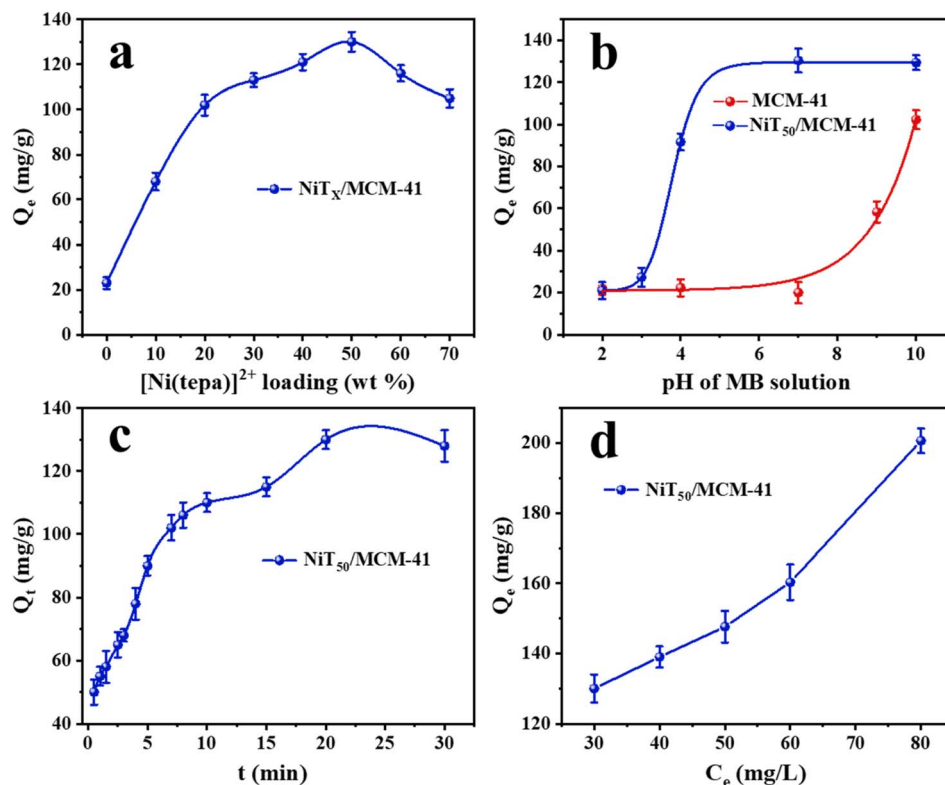


Fig. 2 (a) Adsorption of MB by  $\text{NiT}_x/\text{MCM-41}$  and (b) adsorption of MB by MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$  at different pH values under the following conditions: 50 mL of 30 mg per L MB; adsorbent mass (10 mg); temperature (30 °C); and contact time (30 min). (c) Adsorption of MB by  $\text{NiT}_{50}/\text{MCM-41}$  with different contact times under different conditions: 50 mL of 30 mg per L MB; adsorbent mass (10 mg); and temperature (30 °C). (d) Different initial concentrations; conditions: 50 mL of MB; adsorbent mass (10 mg); temperature (30 °C); contact time (30 min). Error bars represent the degree of data dispersion.

### 3.3 Kinetic studies and adsorption isotherm

The adsorption kinetic data were fitted using pseudo-first-order and pseudo-second-order kinetic models. The fitting results are shown in Fig. 3a and b, respectively, and the fitting data are

given in Table 2. Compared to the  $Q_e$  (exp.) of  $130 \text{ mg g}^{-1}$ , it can be seen that the  $Q_e$  (cal.) obtained using the second-order kinetic fit is closer to the experimental value, and the  $R^2$  value is also better for the second-order kinetic fit. These results show

Table 1 Comparison of the dye adsorption capacities of different adsorbents

Absorbent	$C_0$ (mg L <sup>-1</sup> )	Absorbent mass (mg)	pH	$Q_{\text{max}}$ (mg g <sup>-1</sup> )	Ref.
MCM-41	100	5 g L <sup>-1</sup>	—	16	31
Co-Fe@Al <sub>2</sub> O <sub>3</sub> -MCM-41	100	20	10	100	35
MCM-41	50	20	6.32	5.28	36
Mn/MCM-41				45.38	
MCM-41	100	50	9	149.5	34
Fe-MCM-41				194	
MCM-41	100	1.6 g L <sup>-1</sup>	7	19	37
TiO <sub>2</sub> @mSiO <sub>2</sub>				37	
TiON@mSiO <sub>2</sub>				60	
MCM-41	36	20	7	65.7	38
CuO/MCM-41				87.8	
MCM-41	25	50	—	10.95	32
NiO/MCM-41				23.26	
MCM-41	40	20	6	41.6	30
GDMA/MCM-41				77.6	
MCM-41	30	10	7	23	This work
$\text{NiT}_{50-400}/\text{MCM-41}$				130	

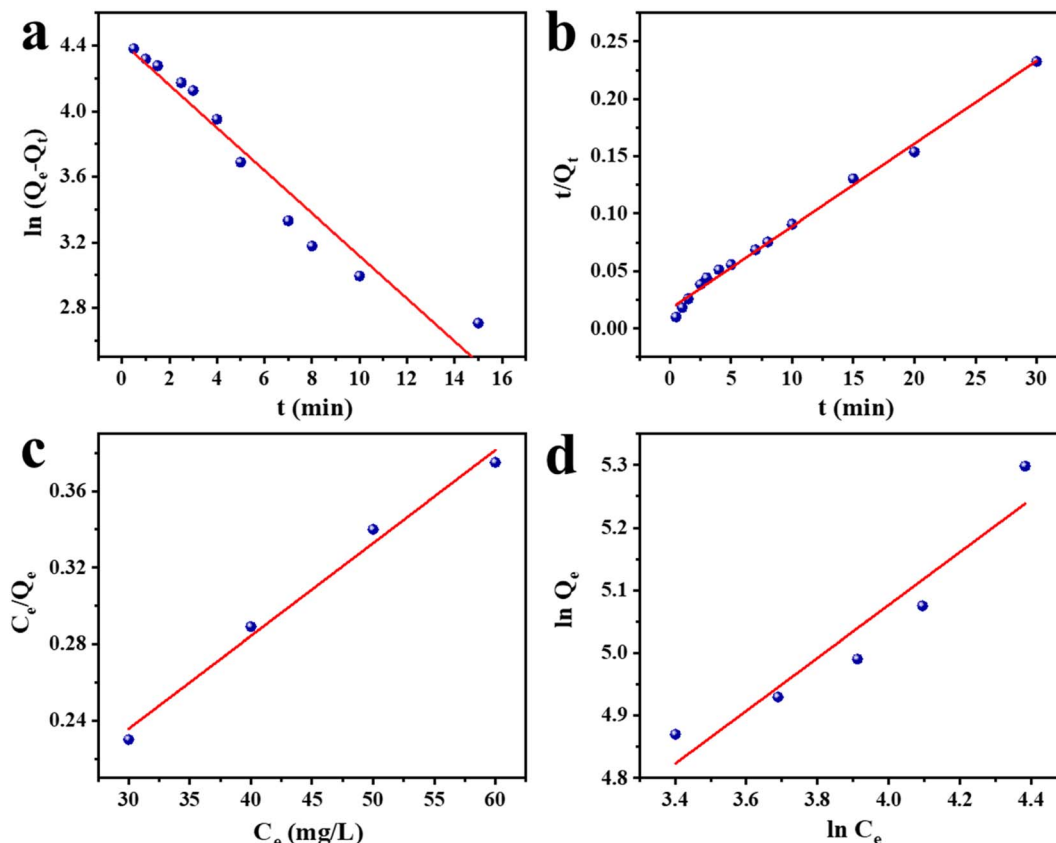


Fig. 3 (a) Pseudo-first-order model, (b) pseudo-second-order model, (c) Langmuir isotherm, and (d) Freundlich isotherm fitting of MB adsorption by NiT<sub>50</sub>/MCM-41.

Table 2 Pseudo-first order and pseudo-second order kinetic parameters for MB adsorption by NiT<sub>50</sub>/MCM-41

Model	$Q_e$ (cal.)	$k$	$R^2$
Pseudo-first-order	12.02	0.13	0.945
Pseudo-second-order	138.80	0.0072	0.993

that the adsorption kinetics of the adsorption process follow a second-order kinetic model. The above-mentioned results indicate that the chemical adsorption between the adsorbent and the dye dominates the adsorption of the dye on NiT<sub>50</sub>/MCM-41, and multiple active sites of NiO<sub>x</sub> and NiC<sub>x</sub> jointly participate in the dye-adsorption process.

The Langmuir and Freundlich equations were used to fit the adsorption isotherms to further investigate the adsorption mechanism. The fitting results are shown in Fig. 3c and d,

Table 3 Langmuir and Freundlich isotherm parameters for NiT<sub>50</sub>/MCM-41

Model	$k$	$R^2$
Langmuir	0.00485	0.981
Freundlich	0.423	0.878

respectively, and the fitting data are presented in Table 3. The adsorption of the isotherm models followed the order of Langmuir > Freundlich. Thus, the results indicate that the adsorption isotherm is more consistent with the Langmuir adsorption model (the linear-fitting correlation coefficient  $R^2$  is close to 1). The Langmuir adsorption isotherm shows that the active sites on the surface of the NiT<sub>50</sub>/MCM-41 adsorbent are occupied in the form of single-molecular-layer adsorption, and no multi-layer stacking adsorption behavior occurs. Moreover, in the NiT<sub>50</sub>/MCM-41 system, the active sites formed after the loading of [Ni(tepa)]<sup>2+</sup> exhibit similar adsorption energies during the adsorption process.<sup>39</sup> In addition, the Freundlich isotherm indicates that multi-layer adsorption may also occur on NiT<sub>50</sub>/MCM-41, with an  $R^2$  of 0.878.<sup>40</sup>

### 3.4 Selective adsorption of mixed solutions of MB/R6G, MB/RhB, and MB/MO

Organic dyes (MB, R6G, RhB, and MO) with various charges and sizes were chosen to evaluate the adsorption and separation properties of MCM-41 and NiT<sub>50</sub>/MCM-41. This study utilized three mixed dye solutions of MB/R6G, MB/RhB, and MB/MO. Fig. 4 illustrates the UV-vis spectra of these binary mixture dye solutions before and after adsorption by MCM-41 and NiT<sub>50</sub>/MCM-41. As depicted in Fig. 4a, after adsorption by MCM-41, the peaks for MB and R6G showed minimal reduction,



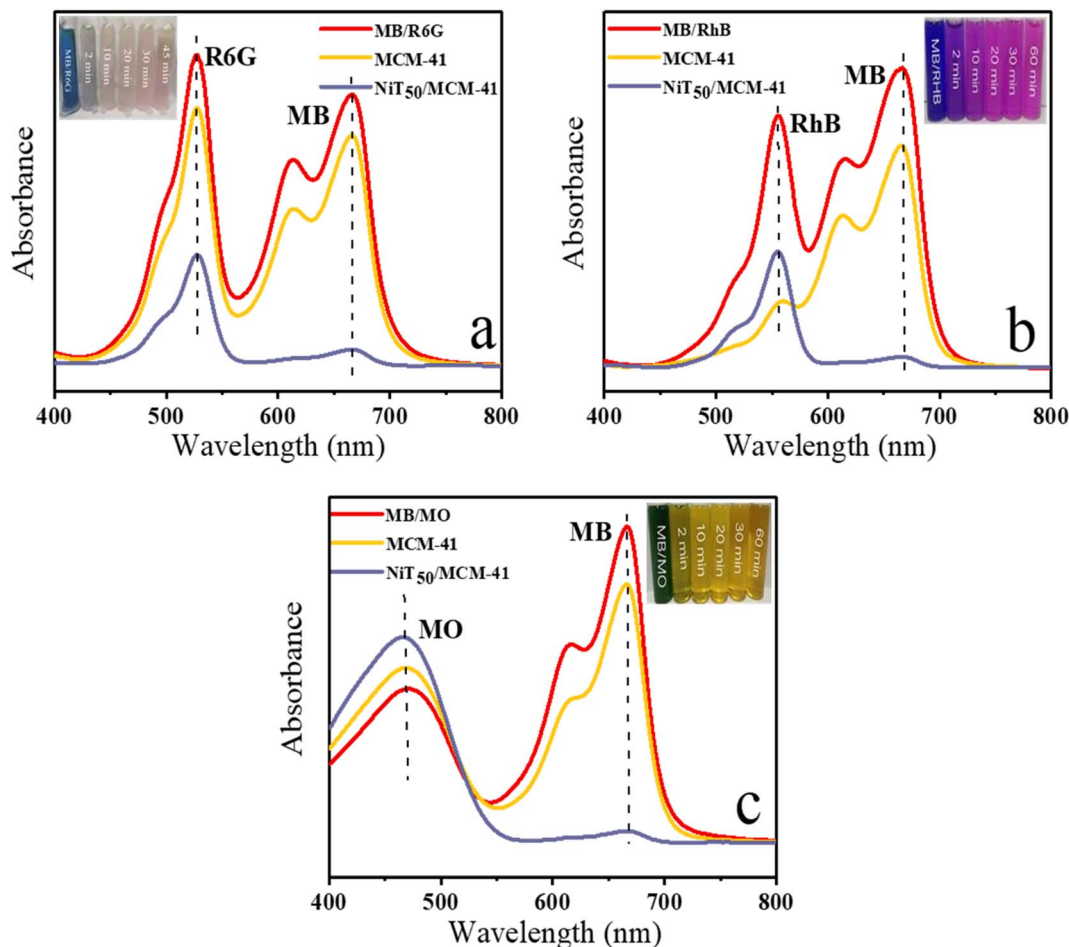


Fig. 4 Selective adsorption capability of MCM-41 and  $\text{NiT}_{50}/\text{MCM-41}$  toward mixed dyes: (a) MB and R6G; (b) MB and RhB; (c) MB and MO. The inset shows the color changes over time of three mixed dye solutions adsorbed using  $\text{NiT}_{50}/\text{MCM-41}$ . Conditions: 50 mL of mixed dye mixture; adsorbent mass (10 mg); temperature (30 °C).

maintaining about 80% of their initial values, indicating the weak adsorption capacity of MCM-41 for MB/R6G. In contrast, after adsorption by  $\text{NiT}_{50}/\text{MCM-41}$ , the peaks for both MB and R6G significantly decreased. The corresponding peak of MB almost completely disappeared, and the corresponding peak of R6G was only about 40% of that before adsorption. The results showed that the MB and R6G adsorption ability of the as-prepared  $\text{NiT}_{50}/\text{MCM-41}$  was obviously greater than that of the original MCM-41 support. The selective adsorption ability for MB in a binary mixture (MB/R6G) was shown based on the difference in the ability of  $\text{NiT}_{50}/\text{MCM-41}$  to adsorb MB and R6G. The inset clearly shows that after adsorption by  $\text{NiT}_{50}/\text{MCM-41}$ , the color of the corresponding adsorbed solution changed from that of the original mixture to the color of R6G. However, the solution adsorbed by MCM-41 has no such change for MB/RhB (in Fig. 4b), and the characteristic peak corresponding to RhB was obviously reduced after adsorption by MCM-41, maintaining only about 25% of that before adsorption, whereas the adsorption of MB was much weaker, still maintaining about 75%. These results indicate that MCM-41 prefers the adsorption of RhB from the mixture. Nevertheless,

after adsorption by  $\text{NiT}_{50}/\text{MCM-41}$ , the corresponding peak of MB almost completely disappeared, and the corresponding peak of RhB was still about 40% of that before adsorption. Compared with that of the original MCM-41 support, the adsorption ability of the as-synthesized silicon-based adsorbent  $\text{NiT}_{50}/\text{MCM-41}$  is obviously greater, and the adsorption of RhB is also suppressed, which shows the selective adsorption ability of  $\text{NiT}_{50}/\text{MCM-41}$  for MB in binary mixtures. On the one hand, the adsorption capacity for MB is significantly enhanced; on the other hand, the adsorption of RhB is inhibited, leading to the selective adsorption of MB in the MB/RhB binary mixture by  $\text{NiT}_{50}/\text{MCM-41}$ . The inset image shows that after adsorption by  $\text{NiT}_{50}/\text{MCM-41}$ , the adsorbed solution turned red, indicating the presence of RhB. Similarly, for the MB/MO mixture, the MB peak remained around 80% after adsorption by MCM-41, whereas it nearly vanished after adsorption by  $\text{NiT}_{50}/\text{MCM-41}$  (Fig. 4c). The inset image clearly demonstrates that following adsorption by  $\text{NiT}_{50}/\text{MCM-41}$ , the solution changed from green to orange, highlighting the superior selective adsorption performance for MB in the MB/MO binary mixture by  $\text{NiT}_{50}/\text{MCM-41}$ .



These results suggest that based on the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” strategy, the cationic [Ni(tepa)]<sup>2+</sup> complex was impregnated onto the negatively charged silica support, followed by suitable thermal treatment, and the silicon-based adsorbent was successfully prepared and showed excellent adsorption capacity and selective adsorption performance for MB.

### 3.5 The mechanism of the new strategy

The mechanism for preparing the silicon-based adsorbent using the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” strategy was further examined using different samples related to MCM-41. MCM-41 was used as the silicon support. Ni-tepa/MCM-41 is a sample with a 50% [Ni(tepa)]<sup>2+</sup> loading mass but without any thermal treatment. NiT<sub>50</sub>/MCM-41, the silicon-based adsorbent developed in this study, has a 50% [Ni(tepa)]<sup>2+</sup> loading mass, followed by thermal treatment at 400 °C. Ni/MCM-41 was prepared using nickel nitrate and MCM-41, ensuring that both the nickel loading and the thermal treatment temperature matched that used for NiT<sub>50</sub>/MCM-41.

The FTIR characterization of the MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41 samples is presented in Fig. 5. In the spectrum of MCM-41, the peaks at 1100, 813, and 472 cm<sup>-1</sup> are attributed to the stretching and deformation vibrations of Si-O-Si.<sup>33,41</sup> The peak at 965 cm<sup>-1</sup> is associated with the asymmetric vibration of Si-OH, while the broad absorption peak near 3440 cm<sup>-1</sup> is due to the O-H stretching vibration. In Ni-tepa/MCM-41, the peaks at 1602 and 1510 cm<sup>-1</sup> correspond to the N-H bending vibration and C-N resonance vibration from tepa, indicating the effective introduction of the cationic complex [Ni(tepa)]<sup>2+</sup> on the silicon support surface.<sup>42</sup> The significant decrease in the intensity of the peak 965 cm<sup>-1</sup> suggests an interaction between the silicon hydroxyl groups and [Ni(tepa)]<sup>2+</sup> during the modification process. The peak at 965 cm<sup>-1</sup> was reduced in all three samples, *viz.* Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41, compared to the original MCM-41 support. It is noteworthy that the Si-OH peaks in Ni-tepa/MCM-41 and NiT<sub>50</sub>/MCM-41, prepared using [Ni(tepa)]<sup>2+</sup>,

were considerably weaker than that in Ni/MCM-41, which was prepared from nickel nitrate.

The XPS spectra were further analyzed to investigate the species present in the samples. Fig. 6 displays the O 1s XPS spectra of MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41. After curve fitting, two oxide components (O<sup>α</sup> and O<sup>β</sup>) were identified in the spectra of MCM-41 and Ni-tepa/MCM-41. In the case of NiT<sub>50</sub>/MCM-41 and Ni/MCM-41, three oxide components (O<sup>α</sup>, O<sup>β</sup>, and O<sup>γ</sup>) were distinguished. The O<sup>α</sup>, O<sup>β</sup>, and O<sup>γ</sup> components correspond to Si-O-Si, Si-OH, and NiO<sub>x</sub>,<sup>43,44</sup> respectively. The low ratios of the C-O and C=O bonds led to their exclusion from this study.<sup>43</sup> The contents of different states of O atoms based on the peak ratio analysis in the O 1s spectrum are shown in Table 4. The proportion of Si-OH in Ni/MCM-41 was 16.1%, showing little change from the raw silicon support MCM-41 (17.7%). However, the Si-OH proportions in Ni-tepa/MCM-41 and NiT<sub>50</sub>/MCM-41 were substantially lower, at 7.5% and 4.7%, respectively, which is consistent with the FTIR findings.

Based on the above-mentioned results, the process for the preparation of silicon-based adsorbents using the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” strategy can be explained as follows: the surface of silica contains many Si-OH groups, which can lose protons to form SiO<sup>-</sup>, resulting in negatively charged surfaces. When a cation is introduced, it attaches to the negatively charged SiO<sup>-</sup> on the silica surface *via* electrostatic interactions. However, only a certain number of Si-OH groups can deprotonate to form SiO<sup>-</sup> under specific conditions. The pH of the [Ni(tepa)]<sup>2+</sup> aqueous solution used was close to 10, providing an alkaline environment, which promotes the deprotonation of Si-OH on the silica surface, increasing the formation of SiO<sup>-</sup>. This environment facilitates the accommodation of the cationic complex [Ni(tepa)]<sup>2+</sup>. This explains why the proportion of Si-OH decreased from 17.7% in the MCM-41 support to 7.5% in Ni-tepa/MCM-41 after loading [Ni(tepa)]<sup>2+</sup>. Comparing NiT<sub>50</sub>/MCM-41 and Ni/MCM-41, which were prepared by impregnating the cations ([Ni(tepa)]<sup>2+</sup> and Ni<sup>2+</sup>) followed by thermal treatment, it was observed that the

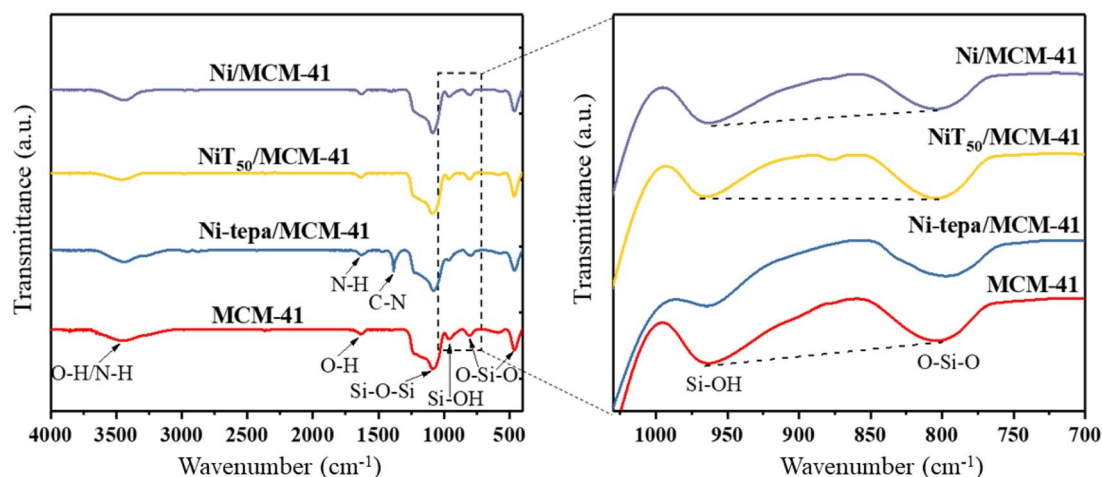


Fig. 5 FTIR spectra of different samples: MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41.





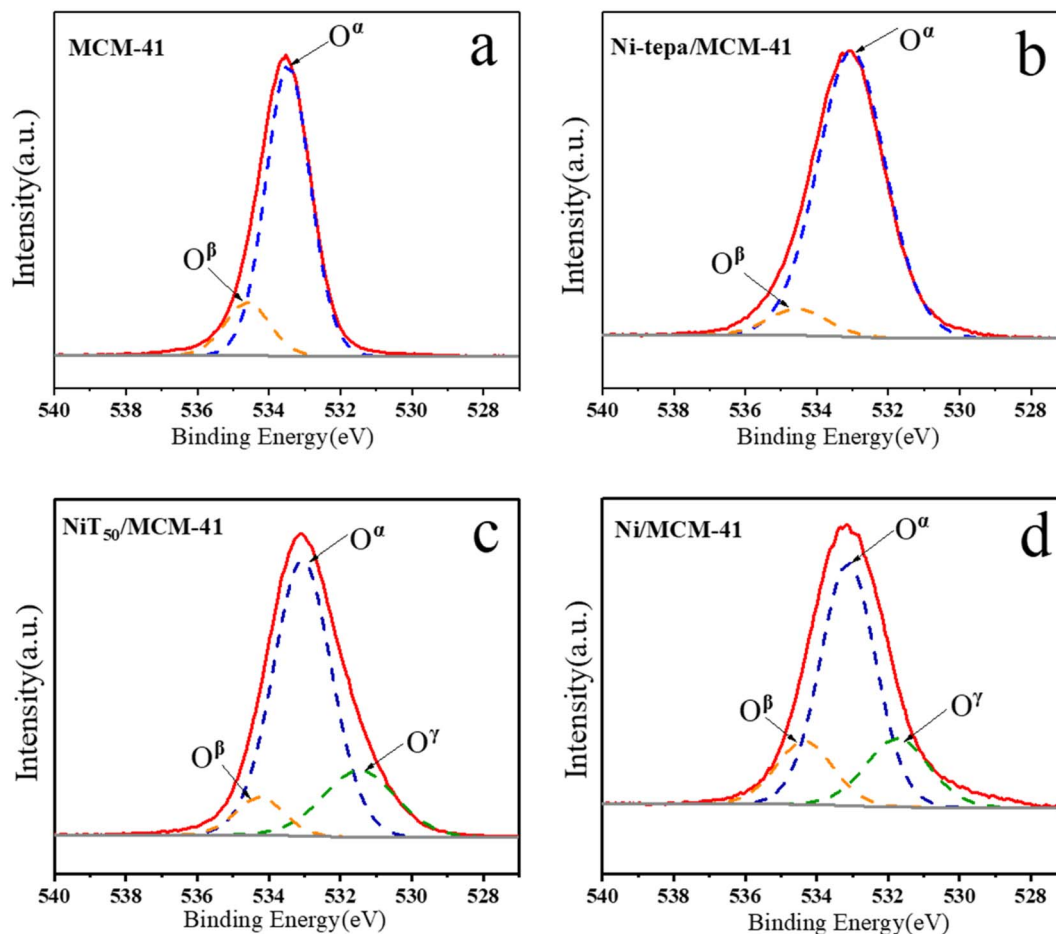


Fig. 6 O 1s spectra of different samples: (a) MCM-41, (b) Ni-tepa/MCM-41, (c) NiT<sub>50</sub>/MCM-41, and (d) Ni/MCM-41.

Table 4 Contents of different O states in MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41 and Ni/MCM-41

Sample	O <sup>α</sup>	O <sup>β</sup>	O <sup>γ</sup>
MCM-41	82.3	17.7	—
Ni-tepa/MCM-41	92.5	7.5	—
NiT <sub>50</sub> /MCM-41	81.1	4.7	14.2
Ni/MCM-41	66.0	16.1	17.9

proportion of Si-OH in Ni/MCM-41 changed slightly to 16.1% from the raw silicon support (17.7%), which is more than three times that of NiT<sub>50</sub>/MCM-41. This is because the nickel nitrate solution is acidic (pH 4), while the [Ni(tepa)]<sup>2+</sup> solution is alkaline (pH 10), making the alkaline environment more conducive to Si-OH deprotonation. In Ni/MCM-41, the many black spots (Fig. S7†) correspond to the NiO particles loaded on the silicon support by nickel nitrate, consistent with the wide-angle XRD results for Ni/MCM-41 (Fig. S8†).<sup>45</sup> However, in the TEM image of NiT<sub>50</sub>/MCM-41, no distinct black spots were observed, indicating highly dispersed nickel species introduced through the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” strategy, which is consistent with the XRD results. The C 1s spectra (Fig. S9†) and HRTEM image of NiT<sub>50</sub>/MCM-41 (Fig. 1c)

suggest that the highly dispersed nickel species in NiT<sub>50</sub>/MCM-41 are NiO and NiC<sub>x</sub>.<sup>46–48</sup> The pore size distribution of Ni/MCM-41 was 2.30 nm, which is only 0.7 nm less than the raw MCM-41 support, while that for NiT<sub>50</sub>/MCM-41 shifted from 2.37 to 2.15 nm. These results indicate that the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” strategy allows more nickel species to enter the mesoporous channels.

Therefore, in the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” process, on the one hand, the [Ni(tepa)]<sup>2+</sup> aqueous solution can provide an alkaline environment, which can promote the deprotonation of Si-OH on the silica surface and lead to the formation of SiO<sup>−</sup>. On the other hand, the introduced cationic complex [Ni(tepa)]<sup>2+</sup> effectively occupies these formed negatively charged sites *via* Coulomb interactions. Then, with suitable thermal treatment, the NiO and NiC<sub>x</sub> components are successfully introduced into the mesoporous channels of the as-prepared silicon-based adsorbent. Fig. 7 is a simple preparation schematic diagram.

### 3.6 Adsorption mechanism

XPS analysis was conducted to further elucidate the adsorption mechanism. X-ray photoelectron spectroscopy (XPS) was performed using a Thermo Scientific K-Alpha instrument in the



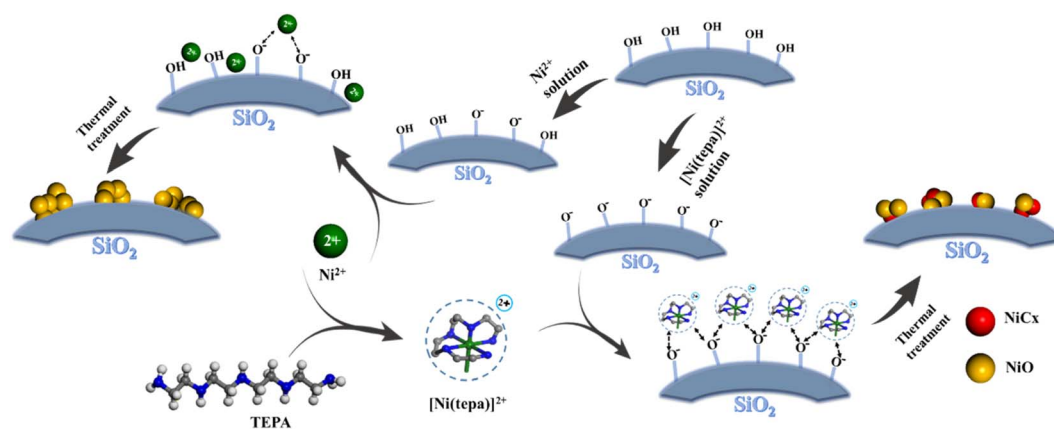


Fig. 7 Schematic of the new strategy.

United States to determine the surface composition of the adsorbent as well as the valence state of the elements. The test results were corrected for the charge effect based on the position of the C (1s) reference peak at 284.8 eV. Also, a peak-fitting analysis was performed on the N 1s spectrum. Fig. 8 displays the N 1s and Ni 2p XPS spectra of NiT<sub>50</sub>/MCM-41, NiT<sub>50</sub>/MCM-41 with adsorbed **MB** (denoted as NiT<sub>50</sub>/MCM-41-**MB**), and

pure **MB**. The Ni 2p spectrum of NiT<sub>50</sub>/MCM-41 (Fig. 8a) could be deconvoluted into three distinct peaks, indicating three different states of Ni species in the silicon-based adsorbent prepared using the “[Ni(tepa)]<sup>2+</sup> modification-thermal treatment” process. The XPS signals at 856.6 eV and 853.3 eV correspond to NiO and NiCx, respectively.<sup>46,49</sup> This observation is consistent with the C 1s spectra (Fig. S9†) and HRTEM image

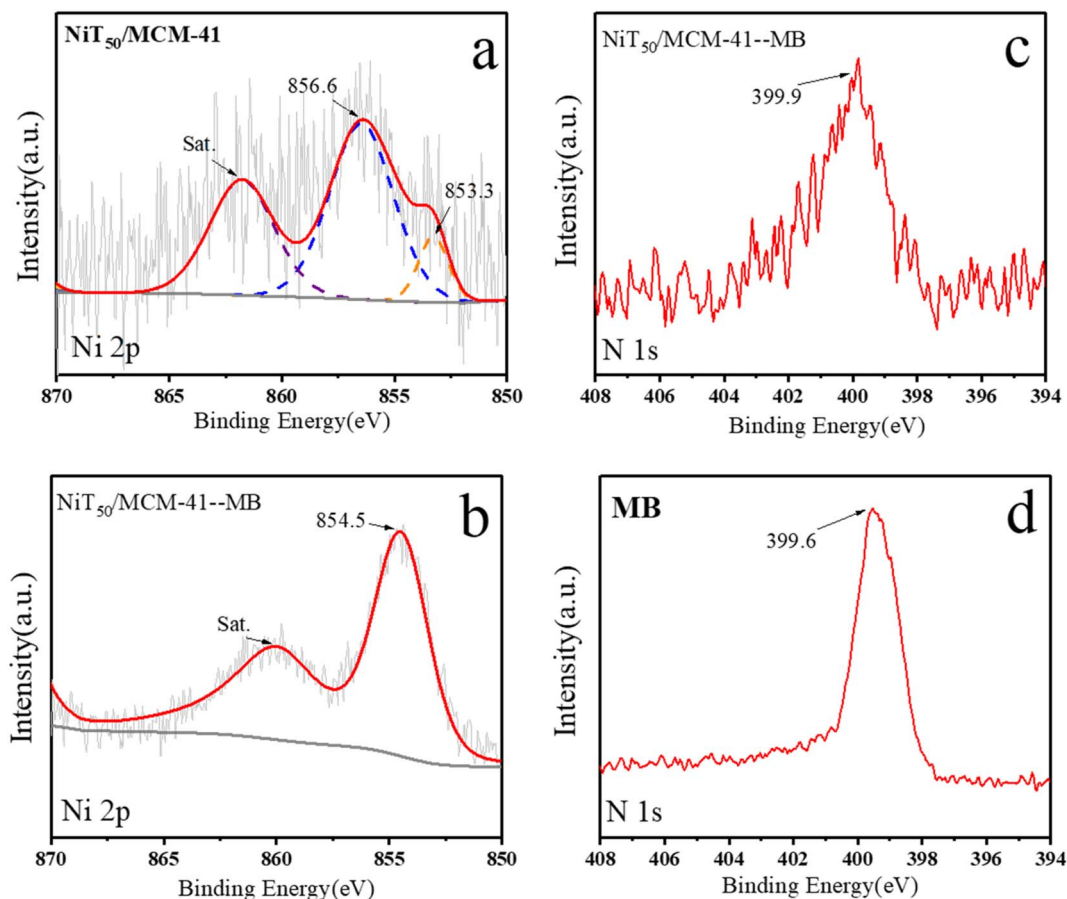


Fig. 8 XPS spectra of the samples. (a) Ni 2p spectrum of NiT<sub>50</sub>/MCM-41, (b) Ni 2p spectrum of NiT<sub>50</sub>/MCM-41 with adsorbed **MB** (denoted as NiT<sub>50</sub>/MCM-41-**MB**), (c) N 1s spectrum of NiT<sub>50</sub>/MCM-41-**MB**, and (d) N 1s spectrum of **MB**.



of NiT<sub>50</sub>/MCM-41 (Fig. 1c). Following the adsorption process (NiT<sub>50</sub>/MCM-41-MB), the Ni species showed a new peak at a binding energy of 854.5 eV. The plausible mechanism was proposed, where cationic dyes such as MB typically contain organic ammonium cations, which can accept electrons and function as Lewis acids. The NiO and NiC<sub>x</sub> components were distributed in the mesopores of MCM-41, resulting in differences in the surface charge density of the nickel species within different states. The electron-withdrawing ability of the O atom provides the electron-attracting ability of the Ni atom in NiO. Therefore, it is not conducive to the adsorption of MB, which tends to accept electrons. However, in the case of NiC<sub>x</sub>, its low binding energy suggests that it can easily provide electrons as a Lewis base. Consequently, based on the Lewis acid-base interaction between MB and NiT<sub>50</sub>/MCM-41, there was a significant change in its Ni 2p spectrum before and after adsorption. This unique subject-object interaction explains the low MB adsorption capacity of Ni/MCM-41, which contains only NiO. The high-resolution N 1s spectra of NiT<sub>50</sub>/MCM-41-MB and pure MB are shown in Fig. 8. The peak at 399.9 eV (Fig. 8c) is assigned to the N atoms of adsorbed MB,<sup>50</sup> which is slightly greater than the binding energy of pure MB (399.6 eV) (Fig. 8d), demonstrating the strong interaction of MB with NiT<sub>50</sub>/MCM-41 through N atoms, which is attributed to Lewis acid-base interactions.

The reasons for the excellent selective adsorption of MB by the silicon-based adsorbent prepared *via* the "[Ni(tepa)]<sup>2+</sup> modification-thermal treatment" strategy were further investigated. Fig. 9 illustrates the adsorption capacities of individual dyes MB, R6G, RhB, and MO by the different samples including MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41. In the case of the cationic dyes MB and R6G, NiT<sub>50</sub>/MCM-41 exhibited significantly higher adsorption capacities (130 and 78 mg g<sup>-1</sup>) compared to MCM-41 (22 and 23 mg g<sup>-1</sup>), respectively. This improvement is attributed to the successful introduction of NiO and NiC<sub>x</sub> components after the [Ni(tepa)]<sup>2+</sup> modification-thermal process, which facilitated the fixation of cationic dyes on the silicon-based adsorbent *via* Lewis acid-base interactions, resulting in efficient adsorption (reaction eqn

(7)). In contrast, Ni-tepa/MCM-41 and Ni/MCM-41 lacked these adsorption sites, leading to much lower adsorption capacities for MB and R6G. Moreover, because the R6G space volume is larger than that of MB and the branched-chain structure of R6G is longer, the diffusion and transfer restrictions of R6G are greater, which results in the adsorption of R6G being lower than that of MB. Although RhB is also a cationic dye, it contains -COOH groups that are easily deprotonated, making RhB electrically neutral under the experimental conditions (pH = 7).<sup>51</sup> The adsorption capacity of MCM-41 for RhB reached 96 mg g<sup>-1</sup>. This high capacity is due to the large specific surface area and pore volume of the raw silicon support, which provides ample adsorption space. Additionally, the COO- groups formed by the deprotonation of -COOH in RhB can easily form hydrogen bonds with Si-OH, fixing RhB to MCM-41. In contrast, the adsorption capacities of Ni-tepa/MCM-41 and NiT<sub>50</sub>/MCM-41 for RhB were much lower, at only 60 and 50 mg g<sup>-1</sup>, respectively. This reduction is because the [Ni(tepa)]<sup>2+</sup> loading modification process promotes the deprotonation of Si-OH (reaction eqn (8)), hindering the adsorption of RhB. [Ni(tepa)]<sup>2+</sup> effectively occupies these negatively charged sites through Coulomb interactions, resulting in its good accommodation (reaction eqn (9)). The zeta potentials of MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41 are -25, -18, and -23 mV, respectively, limiting the adsorption of anionic MO dye due to charge repulsion. However, the zeta potential of Ni-tepa/MCM-41 is close to 0 mV, resulting in the much higher adsorption of MO of about 25 mg g<sup>-1</sup>. In summary, the above-mentioned reasons explain the significantly increased adsorption capacity and excellent selective adsorption of MB by the silicon-based adsorbent prepared using the "[Ni(tepa)]<sup>2+</sup> modification-thermal treatment" strategy.

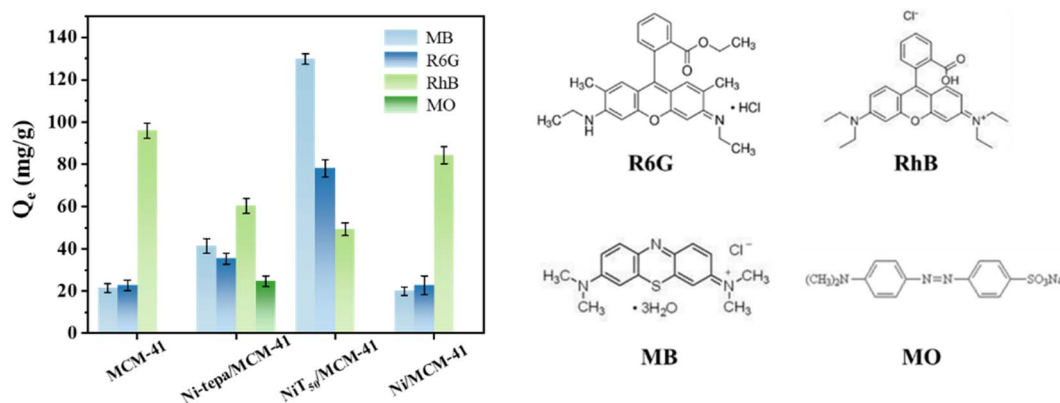
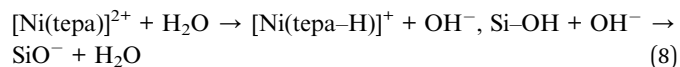


Fig. 9 Adsorption of different dyes (MB, RhB, R6G, and MO) by different MCM-41, Ni-tepa/MCM-41, NiT<sub>50</sub>/MCM-41, and Ni/MCM-41 samples. Error bars represent the degree of data dispersion.

## 4 Conclusions

In summary, a new silicon-based material was successfully created using the "[Ni(tepa)]<sup>2+</sup> modification-thermal treatment" approach and was applied for the selective adsorption of **MB** from aqueous solutions. Using MCM-41 as the silicon support, when the [Ni(tepa)]<sup>2+</sup> loading was 50%, followed by thermal treatment at 400 °C, the adsorption capacity of **MB** by the silicon-based adsorbent (NiT<sub>50</sub>/MCM-41) reached 130 mg g<sup>-1</sup>. This value is significantly higher compared to the raw silicon support MCM-41 (23 mg g<sup>-1</sup>). Additionally, NiT<sub>50</sub>/MCM-41 exhibited excellent selective adsorption properties for **MB** from binary mixed dye solutions (**MB**/R6G, **MB**/RhB, and **MB**/MO). Its adsorption kinetics and adsorption isotherm follow a second-order kinetic model and the Langmuir adsorption model, respectively. During the "[Ni(tepa)]<sup>2+</sup> modification-thermal treatment", the [Ni(tepa)]<sup>2+</sup> aqueous solution provided an alkaline environment, which promoted the deprotonation of Si-OH on the silica surface, increasing the formation of SiO<sup>-</sup>. In addition, the introduced cationic complex [Ni(tepa)]<sup>2+</sup> effectively occupied these negatively charged sites through Coulomb interactions, resulting in its good accommodation. The successful introduction of NiO and NiC<sub>x</sub> components on the surface of the prepared silica-based adsorbent through appropriate heat treatment led to the immobilization of the cationic dye on the silica-based adsorbent through Lewis acid-base interaction, resulting in the excellent selective adsorption of **MB** from mixed solutions (**MB**/R6G, **MB**/RhB, and **MB**/MO).

## Data availability

The authors declare that they did not use databases or AI for the creation of the article.

## Author contributions

Baojuan Luo: conceptualization, formal analysis, investigation, validation, writing – original draft. Menghan Zhang: resources, data curation. Nana Zhou: conceptualization, methodology, investigation. Yongxin Fu: resources, project administration. Xiaoxun Ma: supervision, project administration. Chengyi Dai: supervision, project administration, funding acquisition.

## Conflicts of interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

## Acknowledgements

This work was partly supported by financial support from the National Key Research and Development Program of China (2022YFB4101800), the National Natural Science Foundation of China (22278337), and the Youth Innovation Team

Construction Scientific Research Program of Education Department of Shaanxi Provincial Government, China (23JP171).

## References

- 1 J. McLaren and I. D. Williams, *Sci. Total Environ.*, 2015, **538**, 478–491.
- 2 M. A. Ackacha, K. Poleć-Pawlak and M. Jarosz, *J. Sep. Sci.*, 2003, **26**, 1028–1034.
- 3 D. Chen, S. Chen, Y. Jiang, S. Xie, H. Quan, L. Hua, X. Luo and L. Guo, *RSC Adv.*, 2017, **7**, 49024–49030.
- 4 G. Mahmoud, S. Abdel-Aal, N. El-Kelesh and E. Alshafei, *Environ. Ecol. Res.*, 2017, **5**, 480–488.
- 5 M. A. M. Salleh, D. K. Mahmoud, W. A. W. A. Karim and A. Idris, *Desalination*, 2011, **280**, 1–13.
- 6 C. Xie, *Mater. Today Commun.*, 2024, **41**, 110843–110853.
- 7 P. V. Nidheesh, *RSC Adv.*, 2015, **5**, 40552–40577.
- 8 M. Li, Y. Li, X. Zhang, H. Zheng, A. Zhang, T. Chen, W. Liu, Y. Yu, J. Liu, Q. Du, D. Wang and Y. Xia, *RSC Adv.*, 2020, **10**, 37757–37765.
- 9 N. Al-Bastaki, *Chem. Eng. Process.*, 2004, **43**, 1561–1567.
- 10 E. R. Bandala, M. A. Peláez, A. J. García-López, M. D. J. Salgado and G. Moeller, *Chem. Eng. Process.*, 2008, **47**, 169–176.
- 11 S. Wang, *Dyes Pigm.*, 2008, **76**, 714–720.
- 12 Z. Qiusheng, L. Xiaoyan, Q. Jin, W. Jing and L. Xuegang, *RSC Adv.*, 2014, **5**, 2100–2112.
- 13 Y. Pan, Y. Wang, A. Zhou, A. Wang, Z. Wu, L. Lv, X. Li, K. Zhang and T. Zhu, *Chem. Eng. J.*, 2017, **326**, 454–461.
- 14 M. Samir, H. H. Hassan, H. H. El-Maghrabi and A. A. Nada, *Desalin. Water Treat.*, 2022, **255**, 110–119.
- 15 E. A. Nada, H. H. El-Maghrabi, H. R. Ali, S. A. El-Wahab, D. Y. Sabry, Y. M. Moustafa and A. A. Nada, *Desalin. Water Treat.*, 2022, **255**, 236–241.
- 16 A. A. Nada, B. O. Orimolade, H. H. El-Maghrabi, B. A. Koiki, M. Rivallin, M. F. Bekheet, R. Viter, D. Damberg, G. Lesage, I. Iatsunskyi, E. Coy, M. Cretin, O. A. Arotiba and M. Bechelany, *Appl. Mater. Today*, 2021, **24**, 101129.
- 17 S. De Gisi, G. Lofrano, M. Grassi and M. Notarnicola, *Sustainable Mater. Technol.*, 2016, **9**, 10–40.
- 18 Y.-F. Hui, C.-L. Kang, T. Tian, S. Dang, J. Ai, C. Liu, H.-R. Tian, Z.-M. Sun and C.-Y. Gao, *CrystEngComm*, 2017, **19**, 1564–1570.
- 19 S. Kundu, I. H. Chowdhury and M. K. Naskar, *ACS Omega*, 2018, **3**, 9888–9898.
- 20 F.-Y. Yi, W. Zhu, S. Dang, J.-P. Li, D. Wu, Y. Li and Z.-M. Sun, *Chem. Commun.*, 2015, **51**, 3336–3339.
- 21 S. Tian, W. Liu, B. Liu, H. Li, G. Deng and X. Zhang, *Mater. Today Commun.*, 2023, **35**, 105740.
- 22 M. Algarra, M. V. Jiménez, E. Rodríguez-Castellón, A. Jiménez-López and J. Jiménez-Jiménez, *Chemosphere*, 2005, **59**, 779–786.
- 23 Z. A. AlOthman, *Materials*, 2012, **5**, 2874–2902.
- 24 Z. Teng, X. Su, Y. Zheng, J. Sun, G. Chen, C. Tian, J. Wang, H. Li, Y. Zhao and G. Lu, *Chem. Mater.*, 2013, **25**, 98–105.





- 25 C. Dai, M. Zhang, X. Guo and X. Ma, *Chem. Eng. J.*, 2021, **407**, 127181.
- 26 Y. S. Ho, G. McKay, D. A. J. Wase and C. F. Forster, *Adsorpt. Sci. Technol.*, 2000, **18**, 639–650.
- 27 Y. S. Ho and G. McKay, *Chem. Eng. J.*, 1998, **70**, 115–124.
- 28 I. Langmuir, *J. Am. Chem. Soc.*, 1918, **40**, 1361–1403.
- 29 K. Y. Foo and B. H. Hameed, *Chem. Eng. J.*, 2010, **156**, 2–10.
- 30 Z. Cherifi, B. Boukoussa, A. Mokhtar, M. Hachemaoui, F. Z. Zeggai, A. Zaoui, K. Bachari and R. Meghabar, *React. Funct. Polym.*, 2020, **153**, 104611.
- 31 R. E. Morsi and R. S. Mohamed, *R. Soc. Open Sci.*, 2018, **5**, 172021.
- 32 X. Xiao, F. Zhang, Z. Feng, S. Deng and Y. Wang, *Phys. E*, 2015, **65**, 4–12.
- 33 H. Han, W. Wei, Z. Jiang, J. Lu, J. Zhu and J. Xie, *Colloids Surf., A*, 2016, **509**, 539–549.
- 34 J. P. Dhal, T. Dash and G. Hota, *J. Porous Mater.*, 2020, **27**, 205–216.
- 35 A. C. Pradhan, A. Paul and G. R. Rao, *J. Chem. Sci.*, 2017, **129**, 381–395.
- 36 Y. Shao, X. Wang, Y. Kang, Y. Shu, Q. Sun and L. Li, *J. Colloid Interface Sci.*, 2014, **429**, 25–33.
- 37 A. A. Nada, M. F. Bekheet, S. Roualdes, A. Gurlo and A. Ayril, *J. Mol. Liq.*, 2019, **274**, 505–515.
- 38 Z. Liang, Z. Zhao, T. Sun, W. Shi and F. Cui, *J. Colloid Interface Sci.*, 2017, **485**, 192–200.
- 39 S. Chander, S. Yadav, H. R. Sharma and A. Gupta, *J. Alloys Compd.*, 2024, **986**, 174088.
- 40 S. Chander, S. Yadav, R. Singh, H. R. Sharma and A. Gupta, *J. Ind. Eng. Chem.*, 2024, DOI: [10.1016/j.jiec.2024.10.027](https://doi.org/10.1016/j.jiec.2024.10.027).
- 41 H. Du, X. Ma, P. Yan, M. Jiang, Z. Zhao and Z. C. Zhang, *Fuel Process. Technol.*, 2019, **193**, 221–231.
- 42 Z. Wu, C. Zhang, L. Peng, X. Wang, Q. Kong and X. Gu, *ACS Appl. Mater. Interfaces*, 2018, **10**, 3175–3180.
- 43 W. Bao, X. Liang, Y. Liu, Y. Gao and J. Wang, *IEEE Trans. Dielectr. Electr. Insul.*, 2017, **24**, 2911–2919.
- 44 M.-G. Jeong, E. J. Park, B. Jeong, D. H. Kim and Y. D. Kim, *Chem. Eng. J.*, 2014, **237**, 62–69.
- 45 P. M. Carraro, A. A. G. Blanco, C. Chanquía, K. Sapag, M. I. Oliva and G. A. Eimer, *Microporous Mesoporous Mater.*, 2017, **248**, 62–71.
- 46 W. Zhang, W. Li, Y. Li, S. Peng and Z. Xu, *Catal. Today*, 2019, **335**, 326–332.
- 47 W. Xiong, Q. Guo, Z. Guo, H. Li, R. Zhao, Q. Chen, Z. Liu and X. Wang, *J. Mater. Chem. A*, 2018, **6**, 4297–4304.
- 48 C. Zhang, H. Yue, Z. Huang, S. Li, G. Wu, X. Ma and J. Gong, *ACS Sustain. Chem. Eng.*, 2013, **1**, 161–173.
- 49 C. Yang, L. Fu, R. Zhu and Z. Liu, *Phys. Chem. Chem. Phys.*, 2016, **18**, 4635–4642.
- 50 P. Chen, Z. Cao, X. Wen, J. Wang, F. Yang, P. Qiu, Y. Yue, G. Liu, S. Wang and H. Zhong, *J. Taiwan Inst. Chem. Eng.*, 2017, **80**, 128–136.
- 51 R. W. Ramette and E. B. Sandell, *J. Am. Chem. Soc.*, 1956, **78**, 4872–4878.

